

<b>Notice of References Cited</b>	Application/Control No. 10/520,633	Applicant(s)/Patent Under Reexamination TAKAKUWA, YUJI	
	Examiner Elizabeth Burkhart	Art Unit 1792	Page 1 of 1

**U.S. PATENT DOCUMENTS**

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
	A	US-			
	B	US-			
	C	US-			
	D	US-			
	E	US-			
	F	US-			
	G	US-			
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	I	US-			
	J	US-			
	K	US-			
	L	US-			
	M	US-			

**FOREIGN PATENT DOCUMENTS**

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Country	Name	Classification
	N	JP 2002-075876	03-2002		Motoyama et al	
	O					
	P					
	Q					
	R					
	S					
	T					

**NON-PATENT DOCUMENTS**

*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)
	U	Zhang et al, Low temperature photo-oxidation of silicon using a xenon excimer lamp, Appl. Phys. Lett., Vol. 71, No. 20, 1997, p. 2964-2966.
	V	
	W	
	X	

\*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)  
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